

10/549849

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of :
Jyun IWASHITA et al. : **Mail Stop: PCT**
Serial No. NEW : Attorney Docket No. 2005_1513A
Filed September 23, 2005 :

NEGATIVE RESIST COMPOSITION AND
METHOD OF FORMING RESIST PATTERN
[Corresponding to PCT/JP2004/004080
Filed March 24, 2004]

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In the interest of compact prosecution, please amend the present application as follows:

ATTACHMENT D }